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Structural and optical properties of Zn_{1-x}Co_xO thin films prepared by RF reactive sputtering technique

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Abstract. We have reported the effect of Co doping on structural and optical properties of ZnO thin films prepared by the RF reactive sputtering technique. The composite targets were formed by mixing and pressing ZnO and CoO powders. The thin films were deposited on silica and glass substrates. The structures of samples have been studied by using X-ray diffraction (XRD) and atomic force microscopy (AFM). With the sensitivity of the XRD instruments, the structural analyses of Co-doped ZnO films reveal formation of predominant (002) reflection corresponding to the hexagonal wurtzite structure without any secondary phase. The AFM study showed that surface morphology of the Zn_{1-x}Co_xO films is composed of closely packed nanocrystallites with nanorod shape. The optical properties of the samples were studied using UV-vis absorption and PL spectra. The optical absorption spectra show a red shift of the band edge, which indicates that Co²⁺ ions substitute Zn²⁺ ions in ZnO lattice. In the room-temperature photoluminescence spectra, four main peaks were revealed in all the samples, which are attributed to ultraviolet, violet-blue, blue and green emission.

Keywords: ZnCoO, thin films, RF sputtering, X-ray diffraction, optical absorption, photoluminescence.

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1. Introduction

Diluted magnetic semiconductors (DMS) are semiconducting materials doped with magnetic transition metal (TM) (such as Mn, Fe, Co, Ni etc.) ions have attracted much interest in recent years because of potential application in optoelectronic, their magnetoelectronic and spintronic devices [1-3]. These are basic semiconductors where the cation sites of the host lattice are replaced by transition metal atoms. Recently the family of DMS has been increased by addition of the semiconducting oxides [4, 5].

Zinc oxide (ZnO), an optically transparent II-VI semiconductor with hexagonal wurtzite structure of C_{6v}^4 ($P6_{3mc}$) space group, wide direct band gap ($E_g \sim 3.37 \text{ eV}$), exciton binding energy (~60 meV) has been

identified as a promising host material after theoretical studies that predicted ferromagnetism above room temperature in Mn-doped ZnO [6]. Among those transition metals, cobalt is an important dopant that has been intensively investigated. Different growth techniques such as chemical vapor deposition, spray pyrolysis, pulsed laser deposition, magnetron sputtering, sol-gel process etc. have been used for preparing Co-doped ZnO thin films. The magnetic property of ZnCoO thin films has been the focus of numerous investigations. Several groups [7, 8] have observed ferromagnetism in ZnO:Co systems, while in other groups [9, 10] this magnetic behavior is not observed in similar samples. These controversial results indicated that the magnetic properties are very sensitive to the shape of the samples and to the preparation conditions.

The present work is devoted to preparation of ZnCoO thin films and study of their structural, absorption and photoluminescence properties depending on the content of cobalt.

2. Experimental

 $Zn_{1-x}Co_xO$ (where x = 0.02, 0.04, 0.06) thin films were deposited onto glass and silica substrates using the RF reactive sputtering technique. The composite targets were formed by mixing and pressing ZnO and CoO powders with appropriate ratios of components. The sputtering was performed under a mixture of argon and oxygen atmosphere that served as operation and reactive gases, respectively, through independent mass flow controllers. The sputtering chamber was evacuated down to $2 \cdot 10^{-4}$ Pa before Ar and O₂ gases were filled with the flow ratio 4:1. During the sputtering, the RF power, deposition rate, substrate-to-target distance and substrate temperature were kept at 300 W, 10 nm/min, 35 mm and 350...400 °C, respectively. Postdeposition annealing 5...8 min in oxygen atmosphere at 500...550 °C was performed.

The crystallographic studies were performed using X-ray Diffractometer (D8 ADVANCE X-ray Diffractometer with DAVINCI) using CuK_{α} wavelength (λ = 1.54059 Å) and scanning in 2 Θ range from 10° to 70°.

The surface analysis was performed using atomic force microscopy (AFM) "Nanotec Electronica" in Dynamic Mode (non-contact) with the force constant $K \sim 40$ N/m and $f_0 \sim 300$ kHz. Optical transmission and absorption spectra between 300 and 700 nm were measured using a grating monochromator, photodetector system and registering computer system. This setup was also used to register photoluminescence spectra. For this kind of measurements, the samples were excited using a 325-nm He-Cd laser with the excitation intensity 10 mW.

3. Results and discussion

The X-ray diffraction (XRD) patterns of $Zn_{1-x}Co_xO$ $(0 \le x \le 0.06)$ films are shown in Fig. 1. All intense peak positions of the films correspond to the standard diffraction pattern of ZnO hexagonal wurtzite with a (002) preferred orientation. With an increase in Co content (x > 0.02) additional diffraction peaks were observed, corresponding to (100), (101), and (102) of ZnO. No peaks corresponding to cobalt metal clusters or cobalt oxides were observed on the patterns, which indicates that Co enters the ZnO lattice without changing the wurtzite structures and systematically substitutes Zn^{2+} ions in the lattice. The relative intensity of the (002) peak of $Zn_{1-x}Co_xO$ ($0 \le x \le 0.06$) reaches higher values than that of other peaks, indicating the *c*-axis preferred texture growth of the Co-doped ZnO films. Further, the intensity of diffraction peaks of Zn1-xCoxO films increased with increasing Co concentration, which can be attributed to a refinement and improvement of crystalline quality of these films as a result of Co doping. At the same time, we observed a shift only in the angular peak position of (002) plane, and no angular shift was observed for any other plane. This angular peak shift towards the lower 2Θ value, when transfering from the undoped sample to the doped up to x = 0.04 one, indicates that films are in a uniform state of stress. With a further increase in the Co concentration, the peak shift takes place in opposite direction, i.e. 2Θ value increases, indicating the change in the direction of stress. The average crystallite size *D* was calculated using the full width at the half maximum (FWHM) of the diffraction peak and the angle of diffraction Θ in Debye-Scherer's formula [11]:

$$D = \frac{0.9\lambda}{\Delta\Theta\cos\Theta},\tag{1}$$

where λ is the X-ray wavelength, $\Delta\Theta$ – FWHM, and Θ – Bragg angle of the diffraction peak. The lattice parameters *a* and *c* for the samples were calculated using the appropriate formula and depicted in Fig. 2. Codoping slightly decreases the lattice parameters of the ZnO films, considering that the size of Co²⁺ in tetrahedral configuration (0.058 nm) is close to that of Zn²⁺ in tetrahedral coordination (0.06 nm). Thus, the Co²⁺ ions are systematically substituted by Zn²⁺ ions without changing the crystal structure.

The surface morphology of the $Zn_{1-x}Co_xO$ films and their crystallite sizes have been studied and evaluated by AFM. The root mean square of the surface roughness is measured from the pictures over $5 \times 5 \mu m$ scanning range. The AFM micrograph shown in Fig. 3 indicates that the increase in the surface roughness after Co doping is caused by closely packed nanorod-like nanocrystallites oriented non-perpendicularly to the film-substrate plane over the whole $Zn_{0.98}Co_{0.02}O$ film surface. The estimated diameter of the observed nanorods is about 100 nm. Essentially, there is no obvious change in the microstructure observed in the films grown with different Co concentrations.

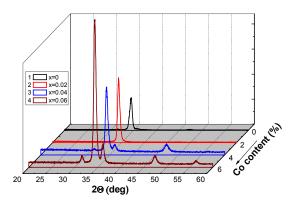


Fig. 1. X-ray diffraction spectra of Co doped ZnO thin films with various doping levels.

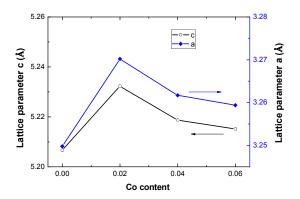


Fig. 2. Variation of lattice parameters *a* and *c* with increasing the Co content in $Zn_{1-x}Co_xO$ thin films.

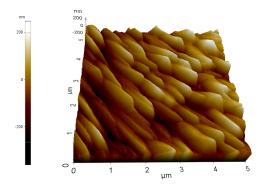


Fig. 3. 3D AFM images of $Zn_{1-x}Co_xO$ thin films with the Co content x = 0.02.

UV-vis optical measurements were carried out at room temperature to study the effect of Co doping concentration on the band gap of ZnO thin films and to confirm the substitution of Co^{2+} ions in tetrahedral sites of the ZnO wurtzite structures. Fig. 4 shows the optical transmission spectra of undoped and cobalt doped ZnO thin films deposited on glass substrates. The undoped ZnO film is more transparent, whereas in cobalt-doped thin films the transmittance decreases with the increase of Co-doping concentration. The optical transmittance spectra showed a shift in the band edge towards the lower energy side with the increase of Co content in the films. Additional absorption below the absorption edge can be seen for the $Zn_{1-x}Co_xO$ thin films. In particular, for the Co content x = 0.02, three absorption bands at about 1.87, 2.03 and 2.19 eV have been revealed, which are in agreement with already reported absorption peaks [12, 13]. This absorption structure is associated with d-delectron transitions of Co²⁺ ions in a tetragonal crystal field. According to Hund's rule and Pauli's exclusion principle, the electronic ground state configuration has L = 3 and S = 3/2. So, the ground state spectral term is ⁴F and the excited state terms are ⁴P, ²G, ²F, ²D and ²P. However, when Co^{2+} exists in the tetrahedral field, the ⁴F term splits into ⁴A₂(F), ⁴T₂(F) and ⁴T₁(F), with ⁴A₂(F) being the lowest in energy and the remaining two having higher energies. The ⁴P term corresponding to the first excited state does not split, but is transformed into ${}^{4}T_{1}(P)$. Similarly, ${}^{2}G$ splits into ${}^{2}A_{1}(G)$, ${}^{2}E(G)$, ${}^{2}T_{1}(G)$ and ${}^{2}T_{2}(G)$. In the ground state, the atom is in ${}^{4}A_{2}$ state. When electron has a sufficient energy, it can be excited to a higher energy state. The observed peaks were attributed to ${}^{4}A_{1}(F) \rightarrow {}^{2}A_{1}(G)$, ${}^{4}A_{2}(F) \rightarrow {}^{4}T_{1}(P)$ and ${}^{4}A_{2}(F) \rightarrow {}^{2}E(G)$ transitions in Co^{2+} ions. Thus, observation of these transitions in transmission spectra of our $Zn_{1-x}Co_{x}O$ films clearly reveals that the added cobalt atoms have been substituted by Zn^{2+} cations and are present in 2+ state.

The optical band-gap energy (E_g) values for these films were evaluated by plotting $(\alpha h v)^2$ versus h v, where hv is the photon energy, and α is the absorption coefficient that can be calculated from the film thickness d as well as transmittances T and T_0 , for the film and substrate, respectively, using equation $\alpha =$ $-(1/d) \ln(T/T_0)$. Extrapolation of the linear portion of $(\alpha h \nu)^2$ to zero gives the value of E_g . The estimated E_g values are decreased with increase of the Co content (Fig. 5). This result is in contrast with the reported data [13, 15] where a blue shift of the absorption edge was observed. On the other side, a similar trend of decrease of the band edge in $Zn_{1-x}Co_xO$ films is reported by many researchers [12, 14, 16]. This low-energy shift of E_g as a function of the Co content can be explained by two reasons: (i) it might result from destabilization of O^{2-} (2p⁶ orbitals at O^{2-} ions adjacent to Co^{2+}), which extends the valence band edge by 0.5 eV [17] or point defects such as nanoclusters of Co, CoO can also lead to this shift [18] (however, these defects have not been observed in the present films); (ii) as mainly due to the s-d and p-d spin-exchange interactions between band electrons and localized d-electrons of Co^{2+} ions substituting Zn^{2+} ions [7, 19]. The exchange interaction between transition metal ions and band electrons gives rise to negative and positive corrections to the conduction and valence-band edges, leading to narrowing the band gap [20].

Room temperature photoluminescence (PL) of Zn_{1-x}Co_xO thin films measured by exciting at 325 nm is shown in Fig. 6. The PL spectra show four peaks occurring around 386, 426, 443, and 538 nm for all the samples on glass and silica substrates. The first peak is in the ultraviolet region, while other three peaks correspond to the violet-blue, blue and green ones, respectively, i.e., in the visible region. The UV emission band is frequently observed in ZnO film and can be attributed to the near-band-edge exciton emission, because the emission energy is almost equal to the band energy of ZnO [21] estimated by UV-vis measurements. With a Co doping content increase, the UV emission center shifts to long wavelengths. It can be attributed to the strong exchange interactions between *d*-electrons of doping ion and s-, p-electrons of the host band [22]. This red shift of near-band-edge emission confirms that the band gap of Zn_{1-x}Co_xO decreases with increasing the Co content and is in good agreement with data obtained

from optical absorption studies. The violet-blue emission centered near 426 nm is probably due to radiative defects related to traps existing at grain boundaries and emitted due to the radiative transition between this level and the valence band [23, 24].

With increasing the Co concentration, the peak position of blue emission shifts slightly to higher wavelengths from 443 up to 448 nm. The mechanism of blue emission (~443 nm) in ZnO low-dimensional

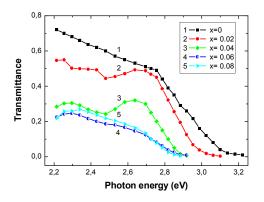


Fig. 4. Transmittance spectra of $Zn_{1-x}Co_xO$ thin films with various contents of Co in the spectral region near the absorption edge.

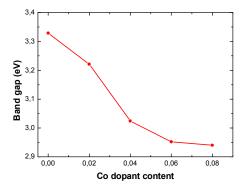


Fig. 5. The energy band gap of $Zn_{1-x}Co_xO$ thin films as a function of the Co content.

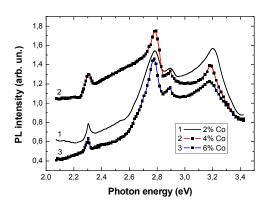


Fig. 6. The room temperature PL spectra of $Zn_{1-x}Co_xO$ thin films with various Co contents.

structures is still controversial. Xu et al. [25] synthesized single crystalline ZnO nanoplates by hydrothermal procedure and attributed blue emission to electron transitions from the level of ionized oxygen vacancies to the valence band. Gokulakrishnan et al. [26] studied Zrdoped ZnO thin films and ascribed the 443-nm centered emission band to a surface defect in the ZnO films. R. Elilarassi, G. Chandrasekaran [27] and Zeng et al. [28] attributed this peak to the interstitial Zn level (Zn_i) and valence band. F.L. Xian et al. [29] attributed the blue emission to the states of interstitial cobalt transition to the valence band. In the latter, it indicates the red shift and change in intensity of emission band with increase of the Co content. The green band emission centered at approximately 538 nm is related to oxygen vacancy, and it is assigned to transitions from single ionized oxygen vacancies (V_0) to the valence band [30, 31].

4. Conclusions

In conclusion, $Zn_{1-x}Co_xO$ thin films with $x \le 0.06$ were deposited by the RF reactive sputtering technique on glass and silica substrates. XRD analysis of the films reveals that cobalt ions are successfully doped in ZnO without changing the hexagonal wurtzite structure. The grown Co-doped ZnO films show c-axis preferred orientation with good crystallinity. AFM study shows that the surface morphology of the $\,Zn_{l-x}Co_xO\,$ films is composed of closely packed nanocrystallites with nanorod shape. The optical absorption spectra of the films demonstrate that the energy band gap was found to decrease with the Co content increase. Band gap narrowing effect occurs due to strong exchange interactions between *d*-electrons of doping ion and *s*-, *p*electrons of the host lattice. The room temperature PL measurements illustrate that UV emission and violetblue, blue and green emissions are in the visible region. The UV emission peak originates from the radiative recombination of free excitons and their center shifts to long wavelengths with increasing the Co content. Other emissions may be attributed to the radiative defects related to traps existing at grain boundaries for violetblue emission, cobalt and zinc interstitial for blue emission, and singly ionized oxygen vacancies (V₀) for green band emission, respectively.

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